X Encontro da SBPMat

Gramado-RS

25 to 29 | september 2011

16 symposia with oral, poster and invited lecture presentations

Plenary lectures

Exhibits

Celebration of 10 years of Brazilian MRS

Conference Details and Registration

All attendees are encouraged to visit the conference website http://www.sbpmat.org.br/x-meeting for further and updated information such as registration, submission of abstracts, important links for traveling (visas, travel agencies) and hotel reservation.

Symposia

A) Magnetic and Superconducting Materials

B) Biodegradable Polymer Materials

C) Electronic Materials

D) Surface Engineering: Fabrication, Characterization, Properties and Applications of Protective Coatings and Modified Surfaces

E) Materials with Negative Properties

F) Nanostructured Functional Materials for Advanced Energy and Environmental Applications

G) Molecular Modeling Materials Science

H) Structure-property Relationship of Advanced Metallic Materials

I) Sol-gel Route to Prepare New Inorganic, Hybrid and Multifunctional Materials

J) Solidification of Metals and Alloys

K) Supramomolecular Organic Materials for Electronic, Photonics and Nanotechnology

L) Structure-Property Relationship of Ceramic Materials: Theoretical and Experimental Aspects

M) Advances and Applications of Electron Microscopy

Prospects for Materials Science with Synchrotron Radiation in Brazil

1st Brazilian Symposium in Friction Stir Welding and Processing

Graphene

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10 years of excellence in the congregation of science and research in materials technology in Brazil

Contact

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Important Dates

April, 5th - Registrations open
May, 30th - Submissions deadline
June, 13th - Acceptance

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Investigation of contact angle and physical properties of the polyaniline (*in-situ* and interfacial polymerization) coated silicon, with potential application as sensitive layer.

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The investigations of the mechanical and physical properties of polymers onto silicon, are considered important in the view point of technological applications, and open a new possibility as sensitive materials, such as quartz microbalance (QMB) oscillators, interdigital capacitors and thermopiles [1]. In this study, the evaluation of hydrophilic and hydrophobic surfaces using contact angle, the morphology of the thin film using atomic force microscopy (AFM) and UV-Visible are presented. The experiments were performed in the silicon surface and silicon with polyaniline (PANI) coating by *in-situ* and interfacial polymerization. The silicon surface with and without polyaniline was evaluated by contact angle (KSV Instruments), all images were obtained in tappingTM mode with scan rate of 1 Hz by atomic force microscopy (Dimension 5000 SPM) and UV-Visible spectra of polyaniline was performed using Shimadzu Spectrophotometer (UV-1601PC) at wavelengths from 900 to 200 nm. The results are showing that silicon present 78° of contact angle, there is more hydrophobic than in-situ and interfacial polymerization, 34° and 64° respectively .AFM images showing a deposition of very thin film of polyaniline and granular morphology onto silicon (Fig. 1 b and c). The roughness of silicon surface was 2.02 nm (Fig. 1a), 133.0 and 104.0 nm for the interfacial and *in-situ* polymerization, respectively (Fig. 1 b and c). Figure 2 shows the spectra of doped polyaniline and was observed two bands around 420 and 800 nm, related to the polaron absorptions, these are due to the cations radicals of poly (semiquinone), typical of conducting polymers. The PANI onto silicon are showing potentiality to apply as a specific sensitive layer.

Keywords: polyaniline, thin film, sensitive layer, AFM.

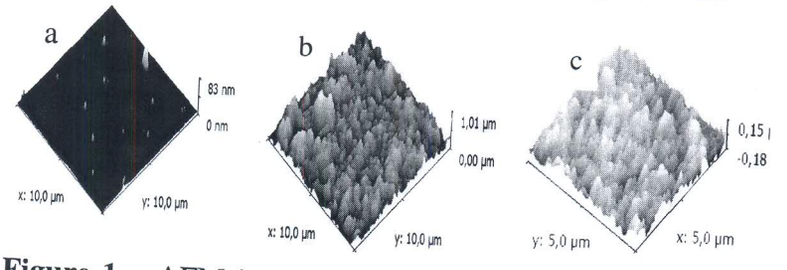

Figure 1 – AFM images cantilever: a) silicon surface, b) interfacial polymerization and c) *in-situ* polymerization.

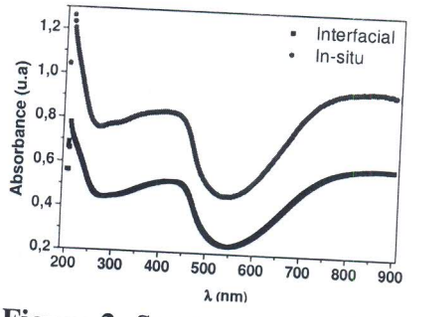

Figure 2- Spectra of UV/Vis of polyaniline.

Work supported Embrapa Instrumentation and INCT/NAMITEC (CNPq.# 573738/2008-4 and FAPESP # 2008/57862-6) and scholarship from Fapesp (# 2009/08244-0).

[1] R. Zhoua, U. Weimar, K.D. Schierbaum, K.E. Geckerler and W. Göpel, Sens Actuators B, **26**, 121-125 (1995).

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